

Number of Components:	Two	Minimum Bond Line Cure Schedule*:	
Mix Ratio By Weight:	10:1	150°C	15 Minutes
Specific Gravity:		80°C	3 Hours
Part A	3.10	23°C	3 Days
Part B	0.96		
Pot Life:	6 Hours	A heat cure is recommended to achieve optimum properties.	
Shelf Life:	One year at room temperature		

Note: Container(s) should be kept closed when not in use. For filled systems, mix the contents of Part A thoroughly before mixing the two parts together. *Please see Applications Note available on our website.

Product Description:

EPO-TEK[®] E4110-LV is a two component, silver-filled epoxy used in electronic and circuit assembly applications in semiconductor and optical industries. A low viscosity version of EPO-TEK[®] E4110.

EPO-TEK[®] E4110-LV Advantages & Application Notes:

- Very low viscosity, silver-filled epoxy which can be applied by hand, brushing, roll coating, tooth-picking or stamping, or spraying.
- After cure, it has a shiny, almost metallic looking finish. This can be used to repair surface imperfections in metal coating applications such as electroplating or sputtering processes.
- Suggested applications:
 - Electronics - filling vias at the PCB level for top-to-bottom connections; EMI & Rf shielding applications.
 - Hybrids - electrically conductive potting for radar systems. The potting can be self-leveling, trapping no voids, and non-cracking with performance.
 - Optics - die-attaching LED's by the stamping process, or pin-transferring applications.
- Passes NASA low outgassing standard ASTM E595 with proper cure - <http://outgassing.nasa.gov>

Typical Properties: (To be used as a guide only, not as a specification. Data below is not guaranteed. Different batches, conditions and applications yield differing results; Cure condition: 150 °C/1 Hour ; * denotes test on lot acceptance basis)

Physical Properties:

*Color: Part A: Silver Part B: Clear/Colorless
 *Consistency: Smooth flowing paste
 *Viscosity (@ 100 RPM/23°C): 350 – 850 cPs
 Thixotropic Index: 1.9
 *Glass Transition Temp.(Tg): ≥ 40°C (Dynamic Cure 20—200°C /ISO 25 Min; Ramp -10—200°C @ 20°C/Min)
 Coefficient of Thermal Expansion (CTE):
 Below Tg: 70 x 10⁻⁶ in/in/°C
 Above Tg: 287 x 10⁻⁶ in/in/°C
 Shore D Hardness: 70
 Lap Shear Strength @ 23°C: 1,080 psi
 Die Shear Strength @ 23°C: ≥ 5 Kg / 1,700 psi
 Degradation Temp. (TGA): 390°C

Weight Loss:

@ 200°C: 0.33%
 @ 250°C: 0.65%
 @ 300°C: 1.19%

Operating Temp:

Continuous: - 55°C to 150°C
 Intermittent: - 55°C to 250°C

Storage Modulus @ 23°C: 469,744 psi

Ions: Cl⁻ 148 ppm
 Na⁺ 18 ppm
 NH₄⁺ 19 ppm
 K⁺ 4 ppm

*Particle Size: ≤ 45 Microns

Electrical Properties:

*Volume Resistivity @ 23°C: ≤ 0.0005 Ohm-cm
 Volume Resistivity @ 23°C (25°C/40-60%RH/3Day cure): ≤ 0.007 Ohm-cm

Thermal Properties:

Thermal Conductivity: 1.24 W/mK

EPOXY TECHNOLOGY, INC.

14 Fortune Drive, Billerica, MA 01821-3972 Phone: 978.667.3805 Fax: 978.663.9782

www.EPOTEK.com

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